

Method of Depositing Buffer Layers on Biaxially Textured Metal Substrates

Disclosure Number

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Technology Summary

A solution containing a target rare-earth is deposited on a RABITS substrate and fired to form an epitaxial layer of the oxide of the rare-earth.

Inventor

SPECHT, ELIOT D

Metals & Ceramics Division

Licensing Contact

DETRANA, ALEXANDER G

Rm 139, Bldg 4500N

1 Bethel Valley Road 6196

Oak Ridge, TN 37831

Office Phone: (865) 576-9682

E-Mail: DETRANAAG@ORNL.GOV
